# DEVELOPMENT OF TIN SELENIDE AND BISMUTH TELLURIDE BASED GRAPHENE COMPOSITES FOR THERMOELECTRIC APPLICATIONS

A Thesis

by

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# MASTER OF SCIENCE

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#### ABSTRACT

Thermoelectric (TE) materials convert thermal energy into electrical energy, and vice versa. Bismuth telluride (Bi<sub>2</sub>Te<sub>3</sub>) is a widely studied thermoelectric material with a high figure-of-merit. Moreover, tin (IV) selenide (SnSe<sub>2</sub>) has recently attracted attention as thermoelectric material due to its predicted excellent TE properties and high performance. Nevertheless, to enable the commercialization of such thermoelectric materials, further improvement in TE performance is required. Nanocompositing is an excellent approach to enhances the properties of TE materials. Graphene is an excellent filler for nanocomposites due to its excellent electrical, thermal, and mechanical properties. In this thesis, pure Bi<sub>2</sub>Te<sub>3</sub> and SnSe<sub>2</sub> and their graphene nanocomposites were synthesized using hydrothermal and solvothermal solution-based methods. Detailed analysis of the chemical composition, the structural morphology, the mechanical and thermal properties, and thermal conductivity of the synthesized thermoelectric materials and their graphene nanocomposites were carried out.

The successful synthesis of  $SnSe_2$  and  $Bi_2Te_3$  was confirmed by XRD and XPS analyses. The nanosize of  $SnSe_2$  with confirmed by XRD and found to ~ 31.5 nm. The incorporation of graphene into the structure of  $SnSe_2$  has improved the mechanical properties of the nanocomposites and decreased the already low thermal conductivity of pure  $SnSe_2$  (0.60 W/m.K) to 0.41 W/m.K, corresponding to a 31.7% reduction with 0.5 wt.% graphene. This decrease in thermal conductivity is expected to enhance the TE properties of  $SnSe_2$ . On the other hand, Bi<sub>2</sub>Te<sub>3</sub> and Bi<sub>2</sub>Te<sub>3</sub>-graphene nanocomposites were also successfully synthesized. The powders were found to have good thermal stability, as evident by the TGA and DSC. The calculated average crystallite size for Bi<sub>2</sub>Te<sub>3</sub> was 33 nm. The addition of graphene reduced the grain size of the nanopowders. Our results show that the addition of graphene to these systems can be a promising method of improving the thermoelectric performance of the materials, and the improvement of mechanical properties may aid in device fabrication for commercial applications.

# **DEDICATION**

Dedicated to my family and friends for their unwavering support, love, patience, and strength, without which this project would not have been possible.

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# NOMENCLATURE

Ср	Specific heat capacity
DOS	Density of states
EDS	Energy Dispersive X-ray Spectroscopy
GO	Graphene oxide
PF	Power Factor
k	Thermal Conductivity
kL	Lattice thermal conductivity
SEM	Scanning Electron Microscopy
σ	Electrical Conductivity
TE	Thermoelectric
TGA	Thermogravimetric Analysis
XPS	X-ray Photoelectron Spectroscopy
XRD	X-Ray Diffraction
ZT	Figure-of-merit

### **CONTRIBUTORS AND FUNDING SOURCES**

### Contributors

This work was supervised by the thesis committee consisting of Professors Ahmed Abdala [advisor] and Konstantinos Kakosimos of the Department of Chemical Engineering and Professor Ibrahim Hassan [co-advisor] of the Department of Mechanical Engineering.

Dr. Yiming Wubulikasimu at the Materials Research Facilities at TAMUQ has carried the XRD, SEM, EDS, and XPS measurements. Dr. Mohammad Ibrahim at the Central Laboratories Unit at Qatar University has carried the DSC analysis. TEM characterization was performed at the Qatar Environment and Energy Research Institute under the supervision of Dr. Said Mansour.

All other work conducted for the thesis was completed by the student independently.

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### **1. INTRODUCTION**

In the current era, fossil fuels are the primary source of power generation. However, energy generated from such sources produces significant amounts of waste heat. A significant component of this waste heat is low-grade waste heat, which is energy lost below a temperature of 230 °C. The power generation sector, followed by the transportation sector, are major contributors to this form of waste heat, as shown in Figure 1.



*Figure 1: Waste heat temperature distribution for different sectors. Adapted from Forman et al.* (2016) [1]

Despite a large amount of low-grade waste heat dissipated from all processes, the recovery of this heat is very low because of its low exergy. Additionally, Carnot's principle states that for a lower temperature gradient, the work available also decreases, which reduces the cost efficiency of the process too. Nevertheless, Rankine cycle-based processes are currently used to recover some of this heat and convert it into usable energy. As steam cannot be used at low temperatures, the working fluids used for these processes consist of benzene or R-134a, which are harmful and environmentally toxic [2]. Therefore, alternative routes must be explored to recover this heat. Due to their form factor adaptability, reliability, and simplicity, thermoelectric generators (TEG) are excellent candidates to be employed for this purpose.

TEGs are preferable as do not require moving parts as a mechanical cycle-based machine would, and they also have a much faster response time. Additionally, there is no chemical discharge during operation, further making them an attractive method for waste heat recovery. TEGs use thermoelectric (TE) materials to recover the waste heat. TE materials work by converting thermal energy – a temperature difference applied across the device – to electrical energy. The reverse effect also occurs. The performance of these materials is defined by a dimensionless number, the *figure-of-merit*, or ZT.

Tin (IV) selenide (SnSe<sub>2</sub>) is an attractive material for TE applications due to its excellent electrical properties and low thermal conductivity. Tin (II) selenide has been found to have remarkable TE performance, but tin (IV) selenide has few studies. A high theoretical ZT of 2.95 has been predicted for SnSe<sub>2</sub>, but experimentally this ZT has not

been reached. This prompts the need for additional studies to investigate methods of improving the properties of SnSe<sub>2</sub>.

Bismuth telluride (Bi<sub>2</sub>Te<sub>3</sub>) is one of the most widely studied TE materials due to its excellent inherent electrical properties. It has been studied since the 1960s, and devices using Bi<sub>2</sub>Te<sub>3</sub>-based materials have been used for cooling modules in small-scale applications, for instance, solid-state refrigerators, thermal sensors, and electronic dehumidifiers. It is the best material for devices operated at room temperature. Some Bi<sub>2</sub>Te<sub>3</sub> based materials have also been used to recover low-grade waste heat. The ZT of Bi<sub>2</sub>Te<sub>3</sub>-based materials has not yet reached 3, which the requirement for commercial applications. Therefore, an improvement in the performance is required to use these devices in large scale applications.

In this thesis, tin selenide and bismuth telluride nanocomposites will be synthesized with graphene using solution methods (hydrothermal and solvothermal). Most studies use solid-state methods, which require pure metals and are cost-intensive. Solution methods will be used for this research as they are cost-effective and easily scalable. The target is a reduction in grain size upon the addition of low amounts of graphene, which will produce materials that have potentially enhanced thermoelectric properties. Graphene is an excellent filler for thermoelectric nanocomposites due to its remarkable thermal and electrical properties. Additionally, the high strength of graphene could improve the quality of the materials for device manufacturing. This thesis aims to enhance the properties by adding graphene and synthesizing the nanocomposites using scalable solution methods.

#### **2. LITERATURE REVIEW**

#### **2.1 Thermoelectric Fundamentals**

### 2.1.1 Thermoelectric Coefficients

The thermoelectric effect that is the basis for the function of TE materials is a combination of three phenomena: the Seebeck, the Peltier, and the Thomson effects. Coefficients corresponding to these phenomena define the behavior of the materials [3].

In 1821, the German scientist Thomas Seebeck noted that when a temperature difference was applied to a circuit made from dissimilar metals, it deflected a compass needle nearby. This phenomenon, known as the Seebeck effect, can be explained by electrons flow from the hot side to the cold side induced by the applied temperature difference. That flow of electrons produces a current in the circuit, and therefore a magnetic field [4, 5]. Seebeck coefficient, S, is defined as the ratio of the voltage to the temperature difference in the system [6]:

$$S = \frac{V}{\Delta T}$$
(1.1)

The units of the Seebeck coefficient are V/K but usually reported in  $\mu$ V/K [6, 7].

In 1836, French scientist Jean Charles Peltier observed that when current passes through a circuit, heat can either be absorbed or dissipated at the junction. This phenomenon is known as the Peltier effect, which is the basis for the TE refrigerators [4]. The Peltier coefficient,  $\pi$ , is defined as the ratio between the current *I* passing through the system, and the heat *q* [6, 8]:

$$\pi = \frac{I}{q} \tag{1.2}$$

The units of the Peltier coefficient are watts/amp (W/A) or V.

The Seebeck and Peltier coefficients are related through the relation [6]:

$$S = \frac{\pi}{T}$$
(1.3)

Lastly, the Thomson effect is related to the rate of generation of reversible heat occurs when current passes through a circuit. The Thomson coefficient,  $\beta$ , is defined as [6]:

$$\beta = \frac{q}{I\Delta T} \tag{1.4}$$

The units for the Thomson coefficient are the Seebeck coefficient units, V/K. The Thomson coefficient, however, is negligible compared to the Seebeck and Peltier coefficients and is often not included when studying thermoelectric materials and their applications [7].

Figure 2 illustrates the circuits within a TE generator and refrigerator, while Figure 3 shows a thermoelectric device.



Figure 2: TE generator (left) and TE refrigerator (right). Both are thermally connected in parallel and electrically in series. For the TE generator, a temperature gradient induces a potential difference that is used to generate energy. A current passes through the TE cooler, inducing a temperature difference, and the cold side absorbs heat. Adapted from Brinks & Huijben (2015) [7].



Figure 3: Schematic of a TE generator. The thermal energy from the heat flow (provided from an external source) is converted to electrical energy. Note that the thermal elements are connected in parallel. Adapted from Saidur et al (2012) [9]

# 2.1.2 The figure-of-merit, ZT

As with any other power generator, a vital aspect of TE devices is the efficiency of the device. The TE performance of a material is measured by the dimensionless figureof-merit, ZT, which is defined by [5-8]:

$$ZT = \frac{S^2 \sigma}{\kappa}$$
(1.5)

where  $\sigma$  is the electrical conductivity,  $\kappa$  is the total thermal conductivity of the material encompassing both lattice ( $\kappa_L$ ) and electronic ( $\kappa_e$ ) contribution, and T is the absolute temperature at which the properties are measured. Figure 4 illustrates the constituents of ZT and the structural properties that should be optimized for ZT enhancement.

For materials with similar thermal conductivities, the performance can be represented by the *power factor (PF)* defined as [10]:

$$PF = S^2 \sigma \tag{1.6}$$

The maximum efficiency of a TE generator ( $\eta$ ) can be determined from ZT using the relation [7]:

$$\eta = \frac{T_{\rm H} - T_{\rm C}}{T_{\rm H}} \frac{\sqrt{1 + ZT} - 1}{\sqrt{1 + ZT} + \frac{T_{\rm C}}{T_{\rm H}}}$$
(1.7)

where  $T_H$  and  $T_C$  are the temperature of the hot and cold junctions, respectively.



Figure 4: ZT and its constituents – Seebeck coefficient (denoted here as  $\alpha$ ), the electrical resistivity ( $\rho$ ), and the thermal conductivity ( $\kappa$ ). These parameters must be optimized by focusing on different aspects of the materials to enhance ZT, as illustrated in figure. Adapted from He & Tritt (2017) [3].

For commercial applications, a ZT of at least three is required [7]. ZT can be maximized by increasing the Seebeck coefficient and electrical conductivity and decreasing the thermal conductivity. High electrical conductivity ensures the flow of current, and the low thermal conductivity means a large temperature gradient can be maintained [5]. However, it is not easy to obtain materials with high electrical conductivity and low thermal conductivity. According to the Wiedemann-Franz Law, the electrical and thermal conductivities are inversely proportional. i.e.  $\lambda/\sigma = \text{constant}$  [11]. Additionally, another problem that arises in increasing the ZT is attributed to the Pisarenko relation -

increasing the electrical conductivity (and hence the concentration of charge carriers) impacts the Seebeck coefficient negatively [12]. Therefore, an "optimum" ZT must be targeted. Section 2.3 Techniques for Improving Thermoelectric Performance discusses the different approaches to improve the ZT of thermoelectric material.

### 2.1.3 Thermal Conductivity

The thermal conductivity ( $\kappa$ ) is an important property that can be tuned for enhancing the TE properties.  $\kappa$  is the sum of the lattice thermal conductivity ( $\kappa_L$ ) and the electronic thermal conductivity ( $\kappa_e$ ). Phonon heat distribution is responsible for  $k_L$ , while heat movement by charge carriers is represented by  $\kappa_e$  ( $\kappa_e = L\sigma T$ , where L is the Lorenz number from Wiedemann-Franz Law, and T is the temperature) [13].

Most TE materials have low electrical conductivity, and heat transfer is dominated by phonon energy transfer.  $\kappa_L$  described by:

$$\kappa_{\rm L} = \frac{1}{3} C_{\rm v} v_{\rm g} l \tag{1.8}$$

where  $C_v$  is the specific heat,  $v_g$  is the group phonon velocity, and *l* is the phonon meanfree path. To reduce  $\kappa_{L,l}$  can be decreased, which is done through various approaches that enhance phonon scattering, such as point-defect scattering, dislocation scattering, boundary scattering, and phonon-phonon Umklapp scattering. Point-defect scattering impacts high-frequency phonons. Dislocation scattering affects middle-frequency phonons, and interface scattering affects low-frequency phonons. These scattering mechanisms can be employed by either forming a solid solution through substitution one atom in the host with an impurity atom or by introducing an interstitial atom (point-defect scattering), by creating dislocations via plastic deformation or clustering of vacancies or interstitial atoms (dislocation scattering), and through forming nanoscale precipitates or nanocomposites, or reducing the grain size (interface scattering). Thus, through microstructure control, phonons in all frequencies can be targeted to reduce the  $k_L$  of a material. It should also be noted that different scattering methods are dominant at different temperatures, as the frequency distribution of phonons varies with temperature. Figure 5 shows how scattering mechanisms vary in their dominance at different temperatures [14]. The decrease in  $k_L$  and its effect on the TE performance is discussed in Sections 2.3.1 Nano-structuring and 2.3.2 Nanocomposites



Figure 5: Different scattering mechanisms and their variance with temperature. Adapted from Hooshmand et al. (2019) [15]

#### 2.1.4 Power Factor

The power factor, PF, is defined as  $S^2\sigma$  and as observed in Equation (1.5), a higher PF means that a higher ZT can be obtained. The carrier concentration *n* can be used to optimize the PF to a satisfactory level. At a higher *n*,  $\sigma$  increases, but S decreases rapidly. Hence, within a range of *n* ( $10^{19} - 10^{20}$  cm<sup>-3</sup> for most semiconductors), a maximum PF can be reached by tuning S and  $\sigma$  optimally, giving *n*<sup>\*</sup>, the optimal carrier concentration [16]. Band structure engineering, carrier concentration optimization, and increasing carrier mobility are used to increase the PF and can all be employed through doping [14]. The mechanism of enhancing the PF via doping is discussed in Chapter 2.3.3 Doping and Alloying

#### **2.2 Thermoelectric Materials**

After discovering the TE phenomena, British physicist John William Rayleigh was the first to attempt to use it for power generation in 1885. His results were inaccurate; however, this was followed by several TE devices being developed in the 19<sup>th</sup> century [17]. These devices were called thermoelectric generators (TEGs), and they consisted of conductors connected in series electrically and parallel thermally. Among these were Cox's pile, made up of zinc, antimony, and tinned iron; the Gulcher and Clammond thermopiles were made up of bismuth, antimony, and iron [18].

However, it was the discovery of the semiconductor technology that advanced the development of TE devices because it led to achieving higher conversion efficiency. In 1947, Maria Telkes at the Massachusetts Institute of Technology constructed a TEG based on lead sulfide (PbS) and zinc antimonide (ZnSb), which achieved an efficiency more than

5% with operation under a temperature difference of 400 K. This was followed by the use of bismuth telluride ( $Bi_2Te_3$ ) thermocouples for cooling at 273 K [17].

Due to their low efficiency, TE devices were not as successful as commercial devices than conventional engines. These were developed for space crafts, as they did not require high efficiency but did require low maintenance and no mechanical moving parts. Despite the numerous possible applications for TE materials, high enough efficiencies have not been reached for these materials. Therefore, they are not used widely used across all areas. However, they have been successfully implemented in smaller applications, for instance, in thermocouples, laser diode coolers, conventional coolers, telecom lasers, and infrared night vision equipment, among others [7, 19]. A significant breakthrough happened for TE devices when radioisotope thermoelectric generators (RTGs) were developed. The first RTG commissioned was SNAP 3 in 1961, for the Navy Transit 4A. An RTG was also used in several other spacecraft, for instance, Apollo 12, Voyager 1, Voyager 2, and the Curiosity rover on Mars [17]. RTGs use the heat from the decay of a radioisotope used for the device to make electricity. Figure 6 shows the different applications of TE materials.



Figure 6: Projected applications of TE materials, according to their power consumption, performance (ZT), and efficiency ( $\eta$ ). Adapted from Freer & Powell (2020) [2]

Materials most commonly used in the manufacturing of TE devices are semiconductors, polymers, and ceramics. Lead, tellurium, and germanium have been often used in TE devices, but new classes of materials are being investigated as these metals are either rare and/or toxic. The properties of the three classes of TE materials – semiconductors, ceramics, and polymers – are summarized in the next sections.

### 2.2.1 Semiconductors

Semiconductors are perhaps the most widely studied material for TE devices, due to their high Seebeck coefficients. Inorganic semiconductors like Bi<sub>2</sub>Te3 and its alloys have high ZT due to its high molecular weight that decreases sound velocity and thus decreases thermal conductivity [20]. Materials with a small bandgap are desirable for use in TE devices. In addition to inorganic semiconductors (PbTe, Bi<sub>2</sub>Te<sub>3</sub>, Mg<sub>2</sub>Si), organic semiconductors are also being studied. These include p-type conducting polymers like poly(3,4-ethylene dioxythiophene) (PEDOT) and n-type conducting polymers such as poly(metal-ethene tetrathiolate) [21]. However, their ZT is not yet high enough for their use in TE devices.

Semiconductor TE materials can also be classified into three types, according to their use-temperature ranges [4]:

- **Bi2Te3 based low-temperature materials:** Used below 400 K
- **PbTe based middle-temperature materials:** Used between 600 and 900 K
- Silicon-Germanium, SiGe, based high-temperature materials: Used at or above 900 K.

#### 2.2.2 Ceramics

Compared to commonly used semiconductors, metal oxides have higher chemical stability, oxidation resistance, and lower toxicity, making them very desirable candidates for TE devices. Cobalt oxides and cadmium oxides are commonly used as p-type and n-type semiconductors in TE devices, as they have desirable TE properties with a maximum of ZT of 0.21 at 973 K for Ca<sub>0.96</sub>Dy<sub>0.02</sub>Bi<sub>0.02</sub>MnO<sub>3</sub>, which is still lower than the ZT for alloys of inorganic semiconductors [20].

#### 2.2.3 Polymers

Polymers have inherently low thermal conductivity, which is an advantage for TE materials. They are also readily available and have low costs of production. They have been studied for use at body temperature to power wearable electronics. Elmoughni *et al.* 

[22] used poly[Na(Ni-ett)] filled with PEDOT based TE integrated into textiles to harvest body heat. Nevertheless, there are still considerable drawbacks to the use of polymer in TE due to, for instance, the electrical resistance of the fabric and the limited power output. Composites of polymers with Bi<sub>2</sub>Te<sub>3</sub>, carbon nanotubes, tellurium powders have been studied [20]. However, high ZT has not yet been reached for polymer-based TE devices.

Due to the low ZT of ceramic and polymer-based TE devices, semiconductors are still the front runners in TE devices. Therefore, this study focuses on two semiconductors: bismuth telluride and tin selenide.

Based on their ZT, TE materials can also be divided into three generations [4]:

- First-generation: ZT is about 1, and the power conversion efficiency for TE devices is between 4-5%.
- Second generation: ZT increased, and power conversion efficiency increased to 11-15%. In this generation, the ZT increased due to the introduction of nanostructures in TE materials. It was suggested that low dimensionality could give a higher S<sup>2</sup> $\sigma$  and a low  $\kappa$  and multiple sources found the ZT for 2D bismuth telluride higher than 3D bismuth telluride [23].
- Third generation: ZT has been increased to almost 1.8, with the power conversion efficiency levels estimated to reach 15-20%. This breakthrough was made due to several different techniques: band engineering either doping or distortion of structure or density of states [24, 25], producing quantum materials [26-28], or multi-scale structure tuning to improve lattice conditions (by changing the phonon scattering) [29].

Figure 7 depicts the evolution of ZT of different TE materials.



*Figure 7: Evolution of ZT of various thermoelectric materials. Adapted from He &Tritt (2017)*[3]

## 2.3 Techniques for Improving Thermoelectric Performance

Several methods have been investigated to increase the performance of TE materials, i.e., increasing ZT. As increasing the electrical conductivity while

simultaneously decreasing the thermal conductivity,  $\kappa_L$ , is limited by the Pisarenko relation, enhancing the performance can be quite challenging. However, several approaches have been developed to enhance the performance of TE materials. These approaches are summarized as follows:

## 2.3.1 Nano-structuring

Dresselhaus and Hicks first introduced the concept of nanostructures in 1993, when they discovered that zero-dimensional (0D), one-dimensional (1D), and twodimensional (2D) could theoretically produce excellent electrical properties as compared to the bulk material. Subsequently, 2D structures such as superlattices, 1D structures such as nanowires, and 0D structures such as quantum dots were prepared, and high ZT were reported for these structures. All of these materials were reported to have low lattice thermal conductivities [5]. In low-dimensional structures,  $\kappa_L$  can be reduced significantly, while the electrical conductivity can be increased to a much more considerable amount than possible in the bulk material [21]. In a Bi<sub>2</sub>Te<sub>3</sub>/Sb<sub>2</sub>Te<sub>3</sub> thin film, a thermal conductivity lower than the 'alloy limit' was achieved. The alloy limit was thought to be the lowest achievable thermal conductivity for bulk material through alloying [30].

Nanostructuring improves the thermoelectric performance by one of two ways. It can improve the thermopower by enhancing the density of states (DOS) near the Fermi level through quantum confinement [30]. The DOS increases with a decrease in the dimensionality [31]. The electron energy bands get narrower as the dimensionality decrease, which improves the Seebeck coefficient due to the increase of high effective masses as a result of the narrow banding [32]. It was found theoretically in 2D multiple-

quantum-well structures, and the quantum-well width decreased compared to the bulk material [33]. A PbTe/Pb<sub>1-x</sub>Eu<sub>x</sub>Te system studied by Hicks *et al.* was the first to prove the quantum-well effect experimentally. They found that the power factor increased several times over that of the bulk material [26].

Decreasing  $k_{\rm L}$  due to increased phonon scattering is another way nanostructuring improves TE performance. As most heat in TE materials is transported by phonons [14], this method does not affect the electrical conduction within the material [30]. Phonon scattering can be enhanced by introducing surfaces or defects into the structure to suppress the mean-free path (mfp) of the photons. The introduction of point-defects to the crystal structure can successfully reduce  $\kappa_L$ . Point-defects can arise from substitution in solid solutions, and it is the mass field and strain field fluctuations between the primary and substituted atoms that contribute to the decrease in  $\kappa_L$ . For CoSbS, the intrinsic thermal conductivity is high due to the stiff chemical bonds between the atoms – however, the introduction of Se in the structure decreases the  $k_{\rm L}$  by 43%. Half-Heusler compounds show a similar pattern upon solid solution formation. A more considerable difference in the atomic masses and radii of the host and substituted atoms is preferable [34]. Vacancies within a structure can also act as point-defects. They can be intrinsic but can also be formed in a solid solution where the substituted compound has a smaller cation-to-anion ratio than the matrix [14]. In a study carried out by Tan *et al.*, it was found that  $k_{\rm L}$  for SnTe decreased by introducing InTe<sub>3</sub> due to the intrinsic high cationic vacancies present in the In<sub>2</sub>Te<sub>3</sub> crystals [34]. Figure 8 illustrates the changes in the  $\kappa_L$  of CoSbS, CuZnSnSe<sub>4</sub>, and SnTe due to different point defects.



Figure 8: Decrease in  $k_L$  due to different point defects: (a) solid solutions, (b) vacancies (c) interstitials. Adapted from Zhou et al. (2018) [14]

Introducing interfaces into a material is an effective way of reducing  $k_L$ . Phonon scattering is significantly increased at the site of the interfaces. These interfaces can arise from having nanoscale precipitates within the structure. A reduction in the grain size can increase the interfaces within a material and lead to higher phonon scattering. A high number of small-angle grain boundaries was achieved in a study conducted by Yang *et al.* on Cu<sub>2</sub>Se with a high density of dislocations in the structure, enhancing the phonon scattering. Due to this, a  $\kappa_L$  around 60% lower than that of bulk Cu<sub>2</sub>Se was obtained [35]. Reducing grain size can be achieved by preparing nanoscale powders by several methods, including ball-milling, melt-spinning, and colloidal synthesis [14]. Bulk quantities of nanostructured materials can be formed by hydrothermal and solvothermal synthesis [36].

### 2.3.2 Nanocomposites

Most nanostructured materials are prepared by methods that are expensive and hard to scale up for commercial use. The use of nanocomposite-based TE materials was introduced to overcome these obstacles. Nanocomposites are essentially bulk materials made up of nanostructured constituents. Nanocomposites are cheaper to produce in large quantities, easier to handle, both in characterization and device fabrication and can be shaped in the desired geometry [28].

To produce nanocomposites with enhanced thermoelectric performance, the aim is to create interfaces that decrease the thermal conductivity by phonon scattering, while not impacting the electrical conductivity negatively. Such interfaces must be carefully selected to ensure the increase in the Seebeck coefficient (through quantum confinement) must be higher than any decrease in the electrical conductivity that improves the power factor, and together lead to the increase of ZT of the TE material [28].

The nanocomposite material, in a powder form, can be obtained through hydrothermal and solvothermal methods, wet-chemical synthesis, high energy ballmilling, and self-precipitation techniques. This powder material is then compacted at a temperature below the melting point to fabricate dense TE material [37]. The resulting material does not usually have the ideal morphology that typical nanostructured materials (nanowires, thin films) have, but do have the required thermal and electrical properties [5].

In a study carried out by Poudel *et al.* found an increase of around 40% in the ZT of p-type BiSbTe nanocrystalline alloy as compared to the bulk material. The nanopowders were produced using ball milling, following which they were hot-pressed. The improvement in the ZT was contributed to the decrease in the thermal conductivity due to increased phonon scattering. The presence of a high number of interfaces from the nanograins within the material enhanced the scattering. The ZT at room temperature was

1.2 and 0.8 at 250 °C, suggesting that it would be an optimal candidate for cooling and low-temperature waste heat recovery applications [38].

Joshi *et al.* prepared bulk p-type SiGe alloy nanostructured material by ball-milling of boron, silicon, and germanium followed by hot-pressing to produce cylindrical pellets. Boron was added for doping the nanopowders. The grains had a mean size of 15 nm. The thermal conductivity, Seebeck coefficient, power factor, and ZT were all higher than that of bulk alloy SiGe. The ZT improved by 50% over the previously recorded value of 0.65, reaching 0.95 at 800 °C. SiGe alloys are used in radioisotope thermoelectric generators (RTG) at temperatures of 1000 °C, and the materials fabricated by Joshi *et al.* obtained a 90% increase in the ZT as compared to the commercially used SiGe alloy. As with the BiSbTe alloy, the high ZT for SiGe was attributed to increased phonon scattering due to the high density of interfaces within the nanocomposite [39].

Nanocomposites of thermoelectric materials with graphene have very favorable results. Graphene is an excellent candidate for use in TE materials as it has high electrical conductivity and excellent mechanical strength, which is a favorable property for being used in devices as well be discussed in detail in Section 2.3 and 2.3.1.

#### 2.3.3 Doping and Alloying

When a foreign element is introduced into the crystal structure of a metallic system, a few lattice sites of the metallic system will be substituted by that foreign element changing the structure of the material and increasing the phonon scattering. The increase in the phonon scattering reduces the thermal conductivity of the material, improving the thermoelectric performance. Doping aims to improve the Seebeck coefficient of the material through band engineering. A high Seebeck coefficient can be attributed to a high DOS with a high effective band mass. However, having a high band mass can negatively impact the mobility of the charge carriers and decrease the conductivity, leading to a net result of no change in the ZT even if the Seebeck coefficient is improved. Hence, the goal of doping is to increase the DOS while keeping the effective band mass low to ensure the electrical conductivity does not decrease [24].

Doping can create resonant levels within the original material, which leads to distortion of the density of states near the Fermi level when the dopant has energy levels in a band of the host material. This distortion can significantly improve the thermopower. Heremans *et al.* [25] doped PbTe with thallium and obtained an increased Seebeck coefficient due to the distortion of states, and ZT of 1.5 at 773 K for p-type Tl<sub>0.02</sub>Pb<sub>0.98</sub>Te, which was 100% higher than the ZT of conventional PbTe alloys (maximum ZT of 0.71 was obtained for Na<sub>0.01</sub>Pb<sub>0.99</sub>Te). Heremans *et al.* [25] also noted that the addition of other group 3 elements, germanium, and indium could also create resonant levels within the original material. The carrier concentration decreases, improving the thermoelectric properties of the material.

Co<sub>4</sub>Sb<sub>12</sub> was doped with La in a study conducted by Nolas *et al.* [40]. The La atoms are loosely bound to the Sb atoms, and the vibration of these atoms scatter phonons that have a similar frequency. This phenomenon is called the resonance scattering mechanism. Resonance can have a significant impact on the  $\kappa_L$  of Co<sub>4</sub>Sb<sub>12</sub>, as shown in Figure 9. Nolas *et al.* also found that a partially filled structure gave better results than a filled structure, as a heavily filled structure increases the carrier concentration but decreases the mobility. A partially filled structure increases both the carrier concentration and the mobility because of the random distribution of the La atoms within the structure.



Figure 9: Effect of resonance on  $k_L$  of  $Co_4Sb_{12}$ . Adapted from Nolas et al. (1998) [40]

While increasing the phonon scattering decreases the thermal conductivity, it can also negatively impact the electrical conductivity. To overcome this, carrier concentration can be tuned. Alloying is an excellent way to tune carrier concentration, which was also achieved in the PbTe system. Pei *et al.* alloyed the PbTe with Mg allowed to increase the bandgap, which decreased the required optimal carrier concentration.

Additionally, doping the material with 2%, Na enhanced the performance further. The temperature dependence of the carrier concentration also decreased, leading to an average ZT that is 40% higher than that of previously reported PbTe system. The maximum ZT achieved by Pei *et al.* was 1.7 at 870 K [41].
Band convergence can positively impact the ZT of the material by increasing the degeneracy states of the material, which increases the effective mass (enhancing the Seebeck coefficient) without impacting the mobility [42]. Li *et al.* [43] doped SnTe with Ge and Sb and noted ZT increase by more than 150% for the sample doped with Ge and Sb compared to the ZT for pure SnTe. It worth noting that the addition of Sb alone did not produce much improvement. A maximum ZT of around 0.85 was reached at 850 K for Sn<sub>0.92</sub>Ge<sub>0.04</sub>Sb<sub>0.04</sub>Te. However, the lattice thermal conductivity of 1.01 Wm<sup>-1</sup>K<sup>-1</sup> was still higher than the amorphous conductivity limit (0.4 Wm<sup>-1</sup>K<sup>-1</sup>) of that composition. To reduce the thermal conductivity, the material was alloyed with 5% Cu<sub>2</sub>Te, and the combination of co-doping and alloying reduced  $k_{\rm L}$  to 0.27 Wm<sup>-1</sup>K<sup>-1</sup> and increased ZT to a maximum of 1.5 at 873 K [43].

## 2.4 Materials Studied

Two materials were studied for this project: bismuth telluride and tin (IV) selenide. They are discussed in detail in the following sections.

#### 2.4.1 Bismuth Telluride

Bismuth telluride (Bi<sub>2</sub>Te<sub>3</sub>) is one of the most widely studied TE materials. Tellurium belongs to the chalcogenide group of metals. Chalcogenide metals are semiconductors that have a bandgap of 1-3 eV. Bismuth has one of the lowest thermal conductivities of any metals, which is an attractive quality for a possible TE material. Bi<sub>2</sub>Te<sub>3</sub> has a quasi-layered lattice structure [44]. The TE performance Bi<sub>2</sub>Te<sub>3</sub> was first discovered in the 1950s. Since then, it has been studied extensively and used widely.  $Bi_2Te_3$  based alloys are widely used in cooling modules used for solid-state refrigerators, thermal sensors, thermopiles, and electronic dehumidifiers [6, 45]. Additionally, nanostructured  $Bi_2Te_3$  can give ZT > 1, which can be used to recover low-temperature waste heat and solar heat [38, 44]. Table 1 summarises the main properties of  $Bi_2Te_3$ :

Parameter	Properties
Crystal structure	Hexagonal-rhombohedral phase
Average lattice constant	$\alpha$ = 4.392 Å, and c = 30.438 Å
Average crystalline size	~ 97 nm
ZT value	0.58 to 1.16
Average diameter	100 – 600 nm
Average width/length	0.1 – 15 μm
Average thickness	10 – 50 nm
Electron affinity	1.87 – 3.44 eV
Band gap	~ 0.15 eV

*Table 1: Properties of bismuth telluride [46]* 

After discovering that low-dimensional materials can have excellent TE properties, the research on Bi<sub>2</sub>Te<sub>3</sub> has focused on producing it in different nanoforms, i.e., nanotubes, nanosheets, nanoflowers, and nanorods. Production of nano-sized Bi<sub>2</sub>Te<sub>3</sub> can be achieved through several methods including solvothermal, hydrothermal, mechanical alloying, water-based chemical reduction, chemical oxidation, wet chemical method, and refluxing [46]. These different methods for the production of Bi<sub>2</sub>Te<sub>3</sub> give different

structures. The characteristics of the chemical and mechanical methods for the preparation of bismuth telluride are summarised in Table 2.

It is evident from Table 2 that the highest ZTs were obtained with samples synthesized via solvothermal or hydrothermal methods or using large-scale zone melting. For this research, a solvothermal method was selected to synthesize bismuth telluride because it is cost-effective, and the potential of the resulting materials having high ZT.

Synthesis Technique	ZT	Cost-	Device- quality	Developed Size	Comments
Solvothermal /hydrothermal	1.16	Low	Best	~ 10 nm	Cost-effective
Straight forward arc-melting	Low	Low	Fair	Pellets	Microstructural characterization difficult
Bridgman	Low	High	Fair	Single crystal	Difficult for device application
Mechanical alloying	Medium	High	Good	$\sim 10 \text{ nm}$	High temperature and pressure
Polyol	Medium	Medium	Poor	$\sim 200 \text{ nm}$	Uses toxic chemical
Water-based chemical reduction	Low	Medium	Poor	~ 300 nm	Particle size cannot be controlled
Chemical oxidation	Low	Medium	Poor	Not uniform	Electrical properties cannot be improved
Wet chemical	Medium	Low	Good	$\sim 30 \ nm$	Uses toxic chemical
Refluxing	Medium	Medium	Good	~ 15 nm	Has to be handled very carefully
Cryogenic grinding	Medium	Medium	Poor	$\sim 70 \text{ nm}$	Not suitable for devices
Large-scale zone melting	ZT = 1.15	Medium	Good	Nano- structure	Microstructural characterization difficult

Table 2: Methods of synthesizing bismuth telluride. Adapted from Mamur et al. (2017) [46]

Table	2	Continued

Synthesis Technique	ZT	Cost	Device- quality	Developed Size	Comments
<b>Facile solution</b>	Medium	Medium	Fair	$\sim 22 \text{ nm}$	Uses toxic chemical

Solution-based methods are also easily scalable compared to solid-state methods. Additionally, Solution synthesized materials give the best device quality material, which is a favourable attribute as the material will eventually be used in a device. A templating ligand can be employed in hydrothermal/solvothermal synthesis to produce unique morphologies – the ligand acts as a chelating agent, which removes any ionic impurities from precursors be present within the final product. Additionally, uniformly sized nanoparticles can be produced using a templating ligand. Commonly used templating ligands include EDTA (ethylenediaminetetraacetic acid), ethylenediamine, polyvinylpyrrolidone, and pyridine [36].

As mentioned in Section 2.3 Techniques for Improving Thermoelectric Performance, an excellent way of improving the TE performance is through doping or alloying. Therefore, tremendous research has been done over the years on doping Bi<sub>2</sub>Te<sub>3</sub> and observing the effect on its TE properties. It was found that doping Bi<sub>2</sub>Te<sub>3</sub> improved the TE performance as compared to pure Bi<sub>2</sub>Te<sub>3</sub>. Samat *et al.* [47] reported an increase of 300% in ZT of Pt doped Bi<sub>2</sub>Te<sub>3</sub> compared to pure Bi<sub>2</sub>Te<sub>3</sub> because of the enhancement in the phonon scattering due to the change of the grain size and the existence of defects in the crystal lattice, which decreased the thermal conductivity. An improvement of ~ 300% in ZT was also reported by An *et al.* [48] via doping with copper. While the electrical conductivity decreased upon doping with copper, the thermal conductivity decreased much further, leading to an increase in ZT. Other studies also reported a decrease in thermal conductivity. Bohra *et al.* [49] reported a 25% improvement in ZT and lowered the thermal conductivity of the lead doped Bi<sub>2</sub>Te<sub>3</sub> than that of pure Bi<sub>2</sub>Te<sub>3</sub>. For Bi<sub>2</sub>Te<sub>3</sub> produced via the hydrothermal route, Yang *et al.* [50] reported ZT of 1.7 for the lutetium doped Bi<sub>2</sub>Te<sub>3</sub>, corresponding to a 90% increase in lutetium doped Bi<sub>2</sub>Te<sub>3</sub>. This enhancement was attributed to increased phonon scattering due to the small grains within the Bi<sub>2</sub>Te<sub>3</sub> grains. Other similar systems are summarized in Table 3, with their TE properties (ZT, thermal conductivity – k, and power factor – PF):

Filler	Preparation Method	к W/m.K	PF μW/m.K <sup>2</sup>	ZT	T K	Ref.
Platinum	Electrodeposition	1	1780	0.65	298	[47]
Copper	Reflux disproportionation and SPS	0.8	1450	0.67	415	[48]
Lead	Vacuum melting	1.62	-	0.63	386	[49]
Lutetium	Hydrothermal and hot pressing	0.62	2850	1.7	373	[50]
CNT	Sonication and ball-	1.1		0.25	200	[51]
Amorphous Carbon	milling	1.1	-	0.25	300	[31]
Silver	Thermal co-evaporation	-	216	-	523	[52]
Silver	Zone melting & hot deformation	1.2	-	1.1	350	[53]
Chromium	Annealing	1.85	950	0.37	400	[54]
Copper	Ball milling and SPS	0.9	-	~0.82	380	[55]
Aluminum oxide	Polyol reduction and SPS	0.85	-	0.2	300	[56]
CNT	Sonication and	0.42		210-5	200	[57]
UHMW PE	compression molding	0.45	-	5X10°	298	[3/]
Lead	Magnetron sputtering and annealing	0.83	2150	1.23	473	[58]
GQD	Solution and SPS	0.65	880	0.55	425	[59]

Table 3: Thermoelectric properties of alloyed and doped bismuth telluride

Filler	Preparation Method	к W/m.K	PF μW/m.K <sup>2</sup>	ZT	T K	Ref.
Germanium		16	3900	09	325	[60]
$(Bi_{39}Ge_1Te_{60})$	Mechanical alloying	1.0	5700	0.9	525	[00]
Germanium	and annealing	1.2	1200	0.45	525	[60]
$(Bi_{32.5}Ge_{10}Te_{57.5})$		1.2	1200	0115	020	[00]
Copper		2	7750	12	300	[61]
$(Bi_{1.99}Cu_{0.01}Te_3)$	Mechanical alloying and	2	7750	1.2	500	[01]
Copper	Annealing	18	250	1.09	363	
$(Cu_2Te)_{0.09}(Bi_2Te_3)_{0.9}$		1.0	230	1.07	505	
Cerium	Hydrothermal and hot pressing	0.5	-	1.29	398	[62]
Iodine	Hydrothermal and hot pressing	0.8	1980	1.1	448	[63]
Selenium	Ball milling and hot pressing	1.15	2500	1.2	445	[64]
Antimony		1.2	-	1.3	380	
Selenium	Hydrothermal and SPS	0.65	1280	0.7	485	[65]
Lanthanum	Hydrothermal and hot pressing	1.5	-	0.58	480	[66]
Graphene	Ball milling and high- frequency induction heating sintering	1.1	1150	0.55	~500	[67]
Graphene	Reflux and pressure pressing	1.575	-	0.37	345	[68]
MWCNT	Hydrothermal and hydrothermal pressing	0.92	_	0.37	333	[69]

### Table 3 Continued

## 2.4.2 Tin Selenide

Tin selenide exists in two forms: tin (II) selenide, SnSe, and tin (IV) selenide, SnSe<sub>2</sub>. They belong to the IV-VI family. SnSe is a p-type semiconductor (conduction is mainly due to the movement of positive holes), while SnSe<sub>2</sub> is an n-type semiconductor (conduction is mainly due to the movement of negative electrons). Tin selenide also has other applications in addition to TE applications. Metal selenides have been used for electrodes for sodium-ion batteries, as they are earth-abundant and have a high specific capacity [70]. Therefore, tin selenide is also a promising candidate for battery applications. The uses of tin selenide also extend to solar energy applications, infrared optoelectronics, photovoltaic cells, and supercapacitors [71].

The potential of SnSe to be used as a TE material was only realized in 2014 when the ZT along the *b*-axis in p-type orthorhombic single-crystal SnSe was found to be 2.6 by Zhao *et al.* at 923 K. This was a record high in bulk TE material. Zhao *et al.* also reported a ZT of  $2.3 \pm 0.3$  along the *c*-axis and a ZT of  $0.8 \pm 0.2$  along the *a*-axis. At room temperature, the ZT along the *b*-axis was in the range of 0.12 - 0.15 [72, 73]. The ZT of SnSe increases as it goes through its transition temperature of 750 K. At this temperature, the structure of orthorhombic SnSe changes from *Pnma* to *Cmcm* [74]. Figure 10 shows the change of ZT with temperature across all three axes.



Figure 10: ZT along all axes of SnSe. The ZT is higher along the b and c axis than the a-axis, showing the anisotropy. Adapted from Zhao et al. (2014) [72]

The ZT of tin selenide at room temperature was found to be improved via doping. Doping with silver (Ag) yields a ZT (0.65), which is higher than that of pure SnSe at 750 K. As the concentration of Ag increases, so does the electrical conductivity. But the Seebeck coefficient and thermal conductivity decrease with an increase in the Ag concentration. The ZT is not high enough to promise good performance [29]. Sodium (Na) doped SnSe posed as a promising TE material – with the increase in the concentration of Na, the thermal conductivity decreases, and the power factor of Na-doped SnSe is higher than that of the pure crystal [75, 76]. However, it is not applicable for devices as the thermal cycle stability of Na-doped SnSe is not great. Recently, germanium (Ge) doped SnSe is being studied. Ge-doped SnSe shows an increased Seebeck coefficient [77].

Although high ZT for SnSe was predicted, these high ZT was based on singlecrystal SnSe that is hard to produce. Polycrystalline SnSe does not have ZT as high as that of a single crystal SnSe, limiting the usage of SnSe in large scale applications [78]. Tin (IV) selenide has not been studied as extensively as tin (II) selenide, but it is a promising thermoelectric material. The crystal structure for tin (IV) selenide is hexagonal closepacked, with lattice parameters of a = 3.811 Å and c = 6.137 Å [79]. The band-gap for this compound is between 0.9-2.04 eV, along with a carrier concentration of  $10^{17} - 10^{19}$  cm<sup>-3</sup>, and electron mobility between 0.6-85 cm<sup>2</sup>/V.s [80].

A few studies have been performed on  $SnSe_2$ , both experimental and theoretical. In the first-principles study carried out by Sun *et al.*, a peak ZT value of 0.88 at 800 K was found. A low lattice thermal conductivity of 0.55 Wm<sup>-1</sup>K<sup>-1</sup> has been predicted for SnSe<sub>2</sub> with a power factor of 1172  $\mu$  Wm<sup>-1</sup>K<sup>-2</sup>. The study also found that the lattice thermal conductivity increased very slightly with an increase in temperature, which is favorable for TE performance [81]. Furthermore, theoretical studies reported a ZT of 2.95 in the aaxis, and a ZT of 0.68 in the c-axis for n-type SnSe<sub>2</sub> [82]. SnSe<sub>2</sub> has a layered structure, which leads to highly anisotropic properties, such as electrical conductivity. The ratio of electrical conductivity in the a-axis to the c-axis  $\sigma_a/\sigma_c$  was 6.92 at 300 K [81]. The layered structure can also improve the TE performance of the material as the thermal and electrical properties can be tuned effectively by controlling the interlayer and layer spacing independently [82]. An illustration of the structure can be seen in Figure 11.



Figure 11: Layered crystal structure of SnSe<sub>2</sub>. Adapted from Saha et al. (2016) [83]

Sun et al. [78] synthesized flower-like nanostructured SnSe<sub>2</sub> via the solvothermal method and obtained ZT of 0.57 at 550 K. This ZT was higher than the ZT reported for other pure SnSe<sub>2</sub>. Saha et al. [83] reported a maximum ZT of 0.15 at 610 K, and Luo et al. [84] also reported the same ZT for pure SnSe<sub>2</sub> nanoplates at 773 K. A room temperature lattice thermal conductivity of a value of 0.67 Wm<sup>-1</sup>K<sup>-1</sup>, which is close to the theoretical minimum lattice thermal conductivity, was reported by Saha et al. [83]. This low thermal conductivity was achieved through doping the synthesized SnSe<sub>2</sub> with chlorine. Doping is a successful way to improve the TE performance of SnSe<sub>2</sub>over that of pure SnSe<sub>2</sub>. The highest ZT was reported by Liu et al. through silver nanoprecipitation and chlorine doping. Ag is present within the nano-precipitates of AgSnSe<sub>2</sub>, and Ag<sup>+</sup> ions insert themselves in the gaps between the layers. Cl doping was performed because the addition of Ag alone is insufficient for optimal carrier concentration. Cl replaces the Se atoms in the structure. Cl doping increases the carrier concentration and the carrier mobility, significantly enhancing the electrical conductivity and, consequently, the power factor. Liu et al. also noted a decrease in the thermal conductivity due to Ag presence in the system, which produced significant defects, enhancing the phonon scattering [85]. The TE properties (ZT, thermal conductivity - k, and power factor - PF) of other doped SnSe<sub>2</sub> systems are summarized in Table 4.

Filler	Preparation Technique	<i>K</i> W/m.K	PF mW/m.K <sup>2</sup>	ZT	T K	Ref.
Chlorine	Solution-based synthesis and hot pressing	0.4	145	0.22	610	[83]
Silver introduction and chlorine doping	Hydrothermal synthesis and SPS	0.6	600	1.03	789	[85]
Chlorine	Hydrothermal synthesis and SPS	1.95	1013	0.3	573	[86]
Chlorine	Solid-state method and SPS	1.25	560	0.56	773	[87]
Silver	Ball milling	1	350	0.4	773	[88]
Silver Chloride	Hydrothermal synthesis and SPS	0.6	275	0.35	673	[89]
Bromine	Melting, quenching, and hot pressing	1.7	-	0.62	750	[90]
Chlorine	Vacuum melting and hot pressing	0.9	400	0.4	673	[91]

Table 4: Thermoelectric properties of doped SnSe<sub>2</sub>

As with bismuth telluride, there are several ways to prepare tin selenide. These include both chemical (hydrothermal/solvothermal, solution-based) methods and mechanical methods. Generally, hydrothermal and solvothermal approaches are preferred due to the ease of controlling the shape, size, and crystallinity of the products by manipulating the process conditions – the temperature at which the synthesis is performed, the synthesis time, the precursor type, and the solvent type [36]. Table 5 summarizes the different methods, the size of the products obtained from those methods, and comments about the process. As nanostructures are better for TE properties, all the methods summarized in the table give a favorable size. The highest ZT was obtained by Sun. *et al.* [78], who followed a hydrothermal approach will be followed.

Preparation Technique	ZT	Developed Size	Comments	Ref.
	0.57	10 nm		[78]
Hydrothermal synthesis	0.15	4.5 nm	Cost-effective method, easy	[85]
	0.02	130 nm	to control parameters	[86]
Solvothermal synthesis	0.15	$20-45 \ nm$		[89]
Solution-based synthesis and hot pressing	0.15	3 – 5 nm	Low-cost and low temperature	[83]
Molting and guanahing	0.09	Incota	High tomporature required	[87]
Menning and quenching	0.02	liigots	right temperature required	[90]
Ball milling	0.028	50-100  nm	Low cost method	[88]
Vacuum melting and hot pressing	0.01	Ingots pressed to 11 mm cylinders	High temperature and pressure required	[91]

Table 5: Synthesis methods for SnSe<sub>2</sub>

# 2.4.3 Graphene

Graphene is the building block of graphite – graphite is made up of layers of graphene stacked on top of each other. It is essentially a layer of  $sp^2$  hybridized carbon atoms, arranged in a honeycomb (hexagonal) lattice structure. Graphene has excellent thermal and electrical properties – it has a thermal conductivity of  $3000 - 5000 \text{ Wm}^{-1} \text{ K}^{-1}$ , and high mechanical strength of around 40 Nm<sup>-1</sup>, with Young's modulus of 1 TPa. It also has a specific area of around 2600 m<sup>2</sup> g<sup>-1</sup>, and carrier mobility of  $\sim 10,000 \text{ cm}^2 \text{ V}^{-1} \text{s}^{-1}$  at room temperature – contributing to the high electrical conductivity of  $10^6 \text{ Scm}^{-1}$  [92, 93]. Graphene can be used to make carbon materials of different shapes – 0D fullerenes, 1D nanotubes, and 3D graphite. Figure 12 visualizes this.



*Figure 12: Various structures derived from graphene. Adapted from Kakaei et al. (2019) [92]* 

Due to its excellent properties in all the various categories, graphene has a wide range of uses. These include chemical sensors, electronic devices, catalysts, energy storage and conversion, green energy applications, etc. Graphene is also being increasingly used to dope metal oxides and producing composited with [92, 93]. As discussed by Heremans *et al.* [23], nanostructures can make excellent TE materials – graphene shows this kind of low dimensionality. However, there are some drawbacks to using graphene – it has a very high thermal conductivity, which negatively impacts the thermoelectric performance as the ZT was relatively low. This problem, however, can be solved in multiple ways as introducing controlled defects, introducing rough edges, edge passivation using hydrogen, patterning, and hybrid nano-structuring [94].

The positive impact of graphene on thermoelectric performance has also been observed in other systems. One such system includes the one studied by Du *et al.* [95]. Polyaniline (PANI) is a conducting polymer with a low thermal conductivity and can be quickly and cost-effectively processed. However, due to its unfavorable electrical properties, it has not been possible to use it as a TE material. The addition of graphene can solve this problem. Graphene nanosheets (GN) were added to the polyaniline in the ratios of 4:1, 3:1, 2:1, and 1:1 (PANI: GN) to prepare pellets and films. As the concentration of GN increased, the electrical conductivity and the Seebeck coefficient of both pellets and films increased. The carrier mobility also increased significantly when the GN concentration was increased, suggesting that this was why the thermoelectric performance improved upon the addition of graphene. The difference in the carrier concentration, however, was not significant. As observed from Figure 13, both the power factor and electrical conductivity ( $\sigma$ ) are highest for an equal weight of GN and PANI.



*Figure 13: The relationship of power factor and electrical conductivity with PANI:GN ratio. Adapted from Du et al. (2012) [95]* 

#### 2.4.3.1 Nanostructured Thermoelectric Material-Graphene Composites

Graphene has been added with and without other dopants to TE materials to improve their performance. Yang *et al.* [96] found that adding molybdenum disulfide with graphene (MoS<sub>2</sub>/G) improves the thermoelectric performance of SnSe. A maximum ZT of 0.98 was achieved at 810 K. Also, the lattice thermal conductivity was decreased due to the introduction of grain boundary scattering.

Thermoelectric properties of  $Bi_2Te_3$  were also found to have improved upon the addition of graphene. In studies carried out by Ahmad *et al.* [67], Liang *et al.* [97], and Ju *et al.* [98], the addition of graphene to  $Bi_2Te_3$  was found to improve the thermoelectric performance. All studies showed a peak at one concentration of graphene, which differed for all three studies. Nevertheless, the addition of graphene improved the performance of  $Bi_2Te_3$ , proving that the addition of graphene should be favorable for TE materials.

Feng *et al.* [99] found that graphene was able to enhance the thermoelectric properties of CoSb<sub>3</sub>, which is a very attractive TE material due to its favorable carrier motility and reasonable band gaps. The limitation of its high thermal conductivity was overcome by introducing a second graphene phase into the CoSb<sub>3</sub> nanostructure matrix in situ. It was found that adding 1.5 wt% graphene to the matrix dramatically improves the figure of merit without a significant adverse effect on the Seebeck coefficient. The variance of ZT is shown in Figure 14.



Figure 14: Material illustration and figure of merit (ZT) for CoSb<sub>3</sub> samples. Adapted from Feng et al. (2013) [99]

Certain TE materials, such as lanthanum strontium titanium oxide (LSTO), are limited in their application due to their high operating temperatures above 700 °C. Lin *et al.* [100] have been not only able to reduce the operating temperature by the addition of graphene but also demonstrated a small (0.6 wt.%) enhances the ZT by more than 280%. Figure 15 illustrates the ZT for different composites of LSTO with graphene.



Figure 15: Variation of ZT with temperature for LSTO-Graphene composites. The peak value of ZT is reached at room temperature, for the composite with 0.6 wt% graphene. Adapted from Lin et al. (2015) [100]

The addition of graphene improves the TE properties due to several reasons. The lattice thermal conductivity of several materials, for example, Bi<sub>2</sub>Te<sub>3</sub>, CoSb<sub>3</sub>, LSTO, and PbTe, was found to have decreased due to a reduction in the grain size, which increases the phonon scattering [67, 96, 99-101]. Phonon scattering was further enhanced due to the introduction of interfaces within the crystal structure, promoting a decrease in the lattice thermal conductivity. As the contribution to the overall thermal conductivity from lattice thermal conductivity is higher than the electronic contribution, the overall thermal conductivity decreases [98]. Graphene used as a filler also enhances the electrical conductivity, by either increasing the carrier concentration or carrier mobility [98, 99]. The thermal stability of composites can also be improved by the addition of graphene [101].

Due to the enhancement of the performance of TE materials upon the addition of graphene, it will be added to the materials prepared in this research to form nanocomposites and possibly further improve the properties of pure bismuth telluride and tin selenide. Doping will also be performed after the composites are synthesized to enhance the performance.

# **3. RESEARCH OBJECTIVES**

The objective of this thesis research is to synthesize bismuth telluride and tin selenidebased graphene composites that could have potentially enhanced thermoelectric properties by using solution methods.

The goal of this research will be met by accomplishing the following objectives:

- 1. Preparing pure tin selenide and tin selenide nanocomposites with different concentration of graphene
- 2. Preparing pure bismuth telluride and bismuth telluride nanocomposites with different concentrations of graphene
- 3. Characterization of the prepared thermoelectric materials and their nanocomposites to establish the correlation between graphene content and the material properties.
- 4. Analyze the properties of the materials for possible thermoelectric applications.

# 4. METHODOLOGY

The general methodology of for this project can be seen in Figure 16:



Figure 16: Flow chart of the methodology

# 4.1 Tin Selenide Fabrication

For the preparation of tin selenide, tin (II) chloride, SnCl<sub>2</sub>.2H<sub>2</sub>O, and selenium dioxide, SeO<sub>2</sub>, were used as the precursors. The precursors were mixed in Sn: Se ratio of 1:2. 7 grams of SnCl<sub>2</sub>.2H<sub>2</sub>O, and 4.44 g of SeO<sub>2</sub> were added to a 250 mL beaker containing 150 mL deionized (DI) water. The solution was stirred for 30 minutes using a magnetic stirrer to ensure no clumps of the precursors remained. It was then bath sonicated for 30 minutes, and probe sonicated for 5 minutes (30 seconds on, 30 seconds off). The sonication was done to ensure the solution was homogenous before the reducing agent was added. The reducing agent used for this process was hydrazine hydrate, N<sub>2</sub>H<sub>4</sub>.H<sub>2</sub>O. 20 mL of the reducing agent was added to the prepared precursor mixture. This solution was then transferred to a 200 mL Teflon liner, placed in an autoclave, and kept in the oven at 180 °C for 9 hours.

The autoclave was then removed from the oven, and the material obtained was centrifuged at 1500 rpm for 10 minutes and repeated five times, and the material was washed with DI water in between to ensure the reducing agent was removed. The material was then dried at 80 °C.

The hydrazine acts as the reducing agent, reducing both the  $Sn^{2+}$  and  $Se^{4+}$ , combining  $SnSe_2$ . The reaction mechanism can be described as follows [102]:

$$SeO_2 + H_2O \rightarrow H_2SeO_3 \tag{4.1}$$

$$H_2SeO_3 + N_2H_4.H_2O \rightarrow Se + N_{2(g)} + 4H_2O$$

$$(4.2)$$

$$2\operatorname{SnCl}_2.2\operatorname{H}_2O + \operatorname{N}_2\operatorname{H}_4.\operatorname{H}_2O \rightarrow 2\operatorname{Sn} + \operatorname{N}_{2(g)} + 5\operatorname{H}_2O + 4\operatorname{HCl} \quad (4.3)$$
  
Sn + 2Se  $\rightarrow$  SnSe<sub>2</sub> (4.4)

#### 4.1.1 Tin Selenide-Graphene Composite Fabrication

For the preparation of tin selenide-carbon composite, a similar procedure to pure tin selenide preparation was followed. The preparation of the precursor mixture was unchanged, but 50 mL DI water was used instead. For the carbon, a graphene oxide (GO) precursor was used. Different concentrations of graphene oxide were used, as shown in Table 6. The graphene oxide solution was made in 100 mL DI water for all the different masses. It was bath sonicated for 15 minutes, followed by probe sonication for 5 minutes (30 seconds on, 30 seconds off). The precursor solution, the graphene oxide solution, and 20 mL hydrazine were added to a 200 mL Teflon liner. The liner was then placed in an autoclave and kept in the oven at 180 °C for 9 hours. A Similar centrifugation and drying procedures were followed for these composites as for the pure tin selenide.

	Mass (g)							
Precursor	% GO							
	0	0.05%	0.1%	0.25%	0.5%			
SnCl <sub>2</sub> .2H <sub>2</sub> O	7.01	7.01	7.01	7.01	7.01			
SeO <sub>2</sub>	4.44	4.44	4.44	4.44	4.44			
GO	0	0.0045	0.009	0.018	0.036			

*Table 6: Mass of the precursors used for the synthesis of* SnSe<sub>2</sub> and SnSe<sub>2</sub>-graphene nanocomposites

# 4.2 Bismuth Telluride Fabrication

The precursors used for the preparation of bismuth telluride were bismuth chloride, BiCl<sub>3</sub>, and pure tellurium powder, Te. In a Teflon lined with 160 mL mixed solution of water and ethanol (50:50), 0.8 g of Hexadecyltrimethylammonium bromide (CTAB) was dissolved, followed by the addition of 8 mmol of BiCl<sub>3</sub> and 12 mmol Te. Sodium hydroxide, NaOH, was added to the solution until the pH was 11. For the Ag-doped Bi<sub>2</sub>Te<sub>3</sub>, Ag<sub>0.011</sub>-Bi<sub>2</sub>Te<sub>3</sub> was prepared, and a stoichiometric amount of silver precursor (AgNO<sub>3</sub>) was added. This mixture was stirred for 15 minutes at room temperature. 32 mmol of sodium borohydride, NaBH<sub>4</sub>, was then added to the mixture. The solution was sealed in an autoclave and was kept in the oven. The oven was maintained at 210 °C for, and the autoclave was removed after 24 hours. The products obtained were filtered in a dead-end cell and washed using distilled water and ethanol, followed by drying at 80 °C. The reaction mechanism followed by the precursors to form  $Bi_2Te_3$  can be described by the equations written below. Both ions and atoms can combine to form the material (following equations 4.7 and 4.8) [103].

 $\operatorname{Bi}^{3+} + \operatorname{OH}^{-} + \operatorname{BH}_{4^{-}} \xrightarrow{} \operatorname{Bi} + \operatorname{H}_{2}\operatorname{BO}_{3^{-}} + \operatorname{H}_{2}$ (4.5)

$$Te + BH_4^- \rightarrow Te^{2-} + H_2BO_3^- + H_2$$

$$(4.6)$$

$$2\mathrm{Bi} + 3\mathrm{Te} \rightarrow \mathrm{Bi}_2\mathrm{Te}_3 \tag{4.7}$$

 $2\mathrm{Bi}^{3+} + 3\mathrm{Te}^{2-} \rightarrow \mathrm{Bi}_2\mathrm{Te}_3 \tag{4.8}$ 

# 4.2.1 Bismuth Telluride-Graphene Composites

For the preparation of tin selenide-carbon composite, a similar procedure to pure tin selenide preparation was followed. The preparation of the precursor mixture was unchanged – the mass used for the precursors and the reducing agent remain the same. For the carbon, a graphene oxide (GO) precursor was used. A GO solution of concentration 1 mg/mL was prepared - an equivalent volume of the GO solution was used as the required mass. It was bath sonicated for 15 minutes, followed by probe sonication for 5 minutes (30 seconds on, 30 seconds off). Different concentrations of graphene oxide were used, as shown in Table 7.

Based on the required volume of the graphene solution, the volume of the precursors' solution was adjusted to ensure the total volume did not exceed 160 mL. The liner was then placed in an autoclave and kept in the oven at 180 °C for 24 hours. The autoclave was allowed to cool to room temperature naturally. The products obtained were filtered in a dead-end cell and washed using distilled water and ethanol, followed by drying at 80 °C.

_	Mass (g)						
Precursor			Sample				
	Pure	Doped	0.25%	0.5%			
<b>BiCl</b> <sub>3</sub>	2.52	2.52	2.52	2.52			
Te	1.53	1.53	1.53	1.53			
GO	0	0	8.02	16.04			
NaBH <sub>4</sub>	1.21	1.21	1.21	1.21			
СТАВ	0.8	0.8	0.8	0.8			
Ag(NO <sub>3</sub> )	0	0.0075	0	0			

Table 7: Mass of the precursors used for the synthesis of Bi<sub>2</sub>Te<sub>3</sub>-based materials

# 4.3 Characterization

Several characterization tests have been and will be performed for this research, summarised in Table 8. They are described in the sections below.

Table 8: Characterization tests performed on the synthesized materials

Matariala	Tests							
viateriais	XRD	XPS	SEM	TEM	TGA	DSC	k	Hardness
SnSe <sub>2</sub>	$\checkmark$							
Bi <sub>2</sub> Te <sub>3</sub>	$\checkmark$	$\checkmark$	$\checkmark$		$\checkmark$	$\checkmark$		

# 4.3.1 Chemical and Structural Properties

# 4.3.1.1 X-Ray Diffraction (XRD)

X-Ray Diffraction (XRD) is used to reveal the crystal structure and chemical composition of materials. It is a non-destructive test, and structural parameters, such as

the average grain size, the crystallinity, the strain, and the crystal defects, can also be obtained. X-rays are scattered by the different lattice planes within a sample. Peaks are obtained due to the constructive interference of x-rays scattered at specific angles [104]. The diffraction from a crystal can be described by Bragg's law, which is given as  $\lambda =$  $2d\sin\theta$ , where d is the interplanar spacing,  $\lambda$  is the wavelength of the x-rays, and  $\theta$  is the diffraction angle or the Bragg angle.

Scherrer's equation is usually used to determine the crystal size [105]:

$$D = \frac{0.9\lambda}{\beta_d} \cdot \frac{1}{\cos\theta}$$
(4.9)

where  $\lambda$  and  $\theta$  are the same as in Bragg's law, and  $\beta$  is the full width at half maximum (FWHM).

However, the Scherrer equation assumes that only the size of the crystals affects the peak broadening, which is inaccurate because the ambient temperature and the lattice strain also affect the width of the peak [106]. Several methods can be used to overcome this, including :

- The **Modified Scherrer** equation can be used, which used a logarithmic model to calculate the crystallite size. This approach reduces the error in the calculation [107].
- The Williamson-Hall (W-H) approach employs a uniform deformation model, a uniform stress deformation model, and a uniform deformation energy density model to obtain the lattice stress and strain parameters yielding a more accurate prediction of the crystallite size [105].

- The Warren-Averbach (W-A) approach uses Fourier-coefficient analysis model and can be applied to a curve of any shape if the tails are correctly truncated. It yields a crystallite size in a good agreement with that obtained experimentally [108].
- The Size-Strain Plot (SSP) method models the size broadening as a Lorentzian function and the strain broadening as a Gaussian function. This method gives more importance to the lower angle peaks as they have more accuracy and precision compared to higher diffractions angles, where the peaks generally overlap [105].
- The Halder-Wagner (HW) method follows the peak broadening as a Voight function. The Voight function is a convolution of Lorentzian and Gaussian functions. XRD peak profiles do not match either fully but have elements of both, which make the HW method accurate as well [105].

In this research, the XRD was carried using Ultima IV X-ray Diffractometer in a scan range of  $10^{\circ}$  to  $80^{\circ}$ , with a speed of  $1^{\circ}$ /minute. CuK (alpha) (0.1542 nm) radiation at 40 kV and 20 mA was used in this analysis.

## 4.3.1.2 X-ray Photoelectron Spectroscopy (XPS)

In X-ray Photoelectron Spectroscopy (XPS), the surface of the material is hit with X-rays under vacuum, causing electrons to be released from the surface. The elemental composition can be obtained for the material as every element will release specific electrons. Additionally, the chemical state of the elements in the material can also be obtained – this can be used to determine what bonds are present in the material. The information obtained from the binding energy of the various elements is compared to the binding energy of the C-C bond, which is always present in the results. It is a non-

destructive technique [104]. For this thesis research, XPS was used to determine the chemical state of bismuth, tellurium, tin, and selenium in their compounds. XPS is also used to quantify the elemental composition

#### 4.3.1.3 Scanning Electron Microscopy (SEM)

Scanning Electron Microscopy (SEM) is used to obtain images of the surface of a material. Unlike XRD and XPS, in SEM, an electron beam is used in this technique. A focused beam of electrons strikes the surface of the material, resulting in the emission of electrons and photons. This interaction produces an image of the surface. The emitted particles are collected by different detectors to yield the results, one of which is used for EDS, discussed in the next section. SEM is performed in a vacuum environment [104, 109]. For this project, the analysis was performed the FEI Quanta 400 Environmental SEM, in high vacuum and on 30 kV.

# 4.3.1.4 Energy Dispersive X-ray Spectroscopy (EDS)

Energy-dispersive X-ray Spectroscopy (EDS) gives the composition of a small area on the surface of the material. It is performed in combination with SEM analysis. When an electron beam strikes a surface, x-rays are also emitted. These x-rays have specific wavelengths that are attributed to different elements. As a result, the elemental composition of the area studied can be obtained [109]. The EDS was performed in conjunction with the SEM, using the EDAX Octane Elect EDS System.

## 4.3.1.5 Transmission Electron Microscopy (TEM)

Transmission Electron Microscopy (TEM) is a powerful technique that can give the crystal structure, deformations within the structure, and morphology of the material. In TEM, imaging of structures at the atomic scale is possible. Similar to SEM, TEM employs electrons. However, in TEM, the electrons are transmitted through the material, and the image is formed using the transmitted electrons collected on a fluorescent screen, as shown in Figure 17. The orientation of the crystal planes can also be determined using TEM.



Figure 17: Working principle of a TEM

#### 4.3.2 Thermal Properties

#### 4.3.2.1 Thermogravimetric Analysis (TGA)

Thermogravimetric analysis is carried out to analyze the thermal stability of materials and also the content of the volatile compound, by monitoring the weight change of the material as it is heated at a constant heating rate. The temperature range in which TGA is conducted depends on the material used. The obtained thermogram of weight versus temperature can also be used to determine the presence of decomposition, oxidation, or dehydration that may occur during heating. TGA can be carried under several environments, including nitrogen, oxygen, air, or vacuum [110]. In this thesis research, TGA was carried out using Discovery TGA (TA Instruments) at the temperature range of 50 °C to 600 °C and a heating rate of 10° C/minute under nitrogen environment.

### 4.3.2.2 Differential Scanning Calorimetry (DSC)

Differential scanning calorimetry (DSC) is a thermal analysis technique in which the difference in the amount of heat required to maintain the temperature of the sample and the reference to follow the programmed temperature scan is recorded. Both materials are maintained at the same temperature throughout the experiment. The melting point, specific heat capacity, heat of fusion, and heat of vaporization of a material can be obtained from this technique [111]. For this research, DSC was carried out from ambient temperature to 450 °C. This test was used for obtaining the heat capacity of the synthesized materials, so calculations for the thermal conductivity could be carried out.

# 4.3.2.3 Thermal Conductivity

The thermal conductivity of thermoelectric materials is an essential property. The thermal conductivity was measured using a LINSEIS LFA 500 Laser Flash, shown in Figure 18. The LFA-500 measures the thermal diffusivity ( $\alpha$ ) of the sample, and the thermal conductivity is determined from the following relation:

$$\lambda = \alpha \rho C_{\rm p} \tag{4.10}$$

where,  $C_p$  is the specific heat capacity and  $\rho$  is the density.

The specimens for measurement were pressed in 25.4 mm disks with a thickness of 0.5 - 2 mm.



Figure 18: Thermal conductivity testing equipment

# 4.3.3 Mechanical Properties

## 4.3.3.1 Hardness Measurement

To analyze the mechanical properties of the synthesized materials, the microhardness of these materials was measured. For these measurements, the nanopowders were pressed into small disks. A pyramidal indenter with a square base makes an indentation on the surface of the disk. The hardness of the material is determined by the prediction size of the indentation and the used load [112]. Figure 19 shows an illustration of the indenter and indentation.



Side view Top view Figure 19: Indenter and indentation made for the microhardness measurements. Adapted from Smallman & Ngan (2014) [113]

#### **5. RESULTS AND DISCUSSION**

#### 5.1 Tin Selenide and Tin Selenide-Graphene Nanocomposites

Pure tin selenide and tin selenide-graphene nanocomposites with different graphene concentrations were synthesized via a hydrothermal approach. A yield higher than 90% was obtained for all materials. The structure and morphology of the pure and nanocomposite samples are analyzed using XRD SEM, TEM, and XPS. The hardness of these materials was also measured, and the results are discussed in the following section.

## 5.1.1 Chemical and Structural Properties

Figure 20 shows the XRD patterns for the pure SnSe<sub>2</sub> synthesized material and the GO composites. The peaks correspond to SnSe<sub>2</sub>, confirming its presence. The diffracted lattice planes are identified in Figure 20, with the  $(10\overline{1})$  plane having the highest intensity. The XRD patterns for the composites show a broader peak near 28° reported for SnSe<sub>2</sub> [114]. The intensities for the peak differ for the composite. However, the peak corresponding to the  $(10\overline{1})$ plane has the highest intensity. Although most peaks in the diffraction pattern correspond to SnSe<sub>2</sub> (JCPDS No. 89-3197), there are peaks at 27.5 and 34.8°, which are not consistent with the SnSe<sub>2</sub> patterns. This extra peak could be due to the presence of oxides within the material. SnO<sub>2</sub> has a peak at 26.5° and 34°, which could correspond to the observed peaks [115]. For the composite samples, the presence of selenium is identified by the peaks at 23.5°, 29.7°, and 51.8° in the XRD patterns and it was also confirmed by the XPS analysis of the composites.



Figure 20: XRD of SnSe<sub>2</sub> and SnSe<sub>2</sub> Composites

An interplanar spacing of 0.29 nm was obtained for the  $(10\overline{1})$  plane, using Bragg's law. The grain size for the crystals was determined using the Williamson-Hall Method. The equation used was:

$$\beta\cos\theta = 4\varepsilon\sin\theta + \frac{k\lambda}{D} \tag{5.1}$$

where,  $\beta$  represents the peak broadening due to the crystal size and the strain,  $\varepsilon$  represents the strain, and  $\theta$  is the diffraction angle. Figure 21 shows the linear fit for  $\beta \cos\theta$  vs  $4\sin\theta$ . The grain size obtained using this method was 31.54 nm.



Figure 21: Williamson-Hall linear fit for pure SnSe<sub>2</sub> nanopowders

However, as the R<sup>2</sup> squared value obtained from the Williamson-Hall method did not suggest a good fit, the data were also analyzed using the Warren-Averbach method. The equation for the Warren-Averbach method is as follows:

$$\frac{\beta^2}{\tan^2\theta} = \frac{\lambda}{D} \left(\frac{\beta}{\tan\theta\sin\theta}\right) + 25e^2$$
(5.2)

Figure 22 shows a linear fit for  $\frac{\beta^2}{\tan^2 \theta}$  vs  $\frac{\beta \lambda}{\tan \theta \sin \theta}$ , The grain size and strain were obtained from the slope and the intercept, respectively. The R<sup>2</sup> for the Warren-Averbach method is higher, suggesting that this method is a better fit. The grain size was 36.5 nm, and the strain was 0.04 %.



Figure 22: Warren-Averbach linear fit for pure SnSe<sub>2</sub> nanopowders

The procedure mentioned earlier was followed to obtain the grain sizes of the SnSe<sub>2</sub> composites with graphene, and the results are summarised in Table 9. The results show that the addition of graphene reduces the grain size of the materials, with the smallest grain size of 25.1 nm for the 0.5% GO nanocomposite. The lack of a clear trend in the grain size calculations could be due to the presence of selenium within the graphene nanocomposites, which could have affected the grain size of our obtained products. Nevertheless, there was a decrease of 31.3% upon the addition of 0.5% GO. The Warren-Averbach model suggested a better fit for the composites, similar to the pure SnSe<sub>2</sub> linear fits. The linear fits for the composites can be found in Appendix A.1.

CO Concentration (9/)	Grain Size (nm)						
GO Concentration (70)	<b>Scherrer's Method</b>	Williamson-Hall	Warren-Averbach				
<b>0 (Pure)</b>	33.1	31.5	36.5				
0.05	26.7	33.00	25.4				
0.1	28.9	23.9	29.3				
0.25	27.2	29.5	35.07				
0.5	27.6	22.3	25.1				

 Table 9: Grain sizes for pure SnSe2 and SnSe2-Graphene composites obtained using Scherrer,

 Williamson-Hall, and Warren-Averbach methods

In addition to XRD, XPS was carried out to investigate the chemical states of the elements and their composition. Figure 23 (a) and (b) show the spectra for Sn 3d and Se 3d. The Se spectrum has only two peaks at 54.5 eV, 55.4 eV, corresponding to SnSe<sub>2</sub>, and 487 eV and 495.4 eV, corresponding to SnO<sub>2</sub>. Table 10 summarises the elemental quantification of the materials, showing a large amount of oxygen due to the presence of the oxides.

Figure 24 shows the spectra obtained for SnSe<sub>2</sub>-0.50% GO verifies what was observed in the XRD – the presence of two phases, both SnSe<sub>2</sub> and Se. The binding energies of 53.6 and 54.5 eV correspond to Se<sup>2-</sup> in SnSe<sub>2</sub>, and the binding energy of 55.5 eV corresponds to pure selenium. The presence of tin oxide is once again observed in the tin spectra – the 3d peaks for tin appeared at 486 eV and 494.4 eV, and 488 eV and 496.4 eV. The former corresponds to Sn<sup>4+</sup> in SnSe<sub>2</sub>, while the latter corresponds to its presence SnO<sub>2</sub>. The peak for oxygen at 532 eV corresponds to moisture absorbed on the surface [116], and the peak at 529.7 corresponds to oxygen in the Sn-O bond.


Figure 23: (a) Survey spectra of the pure SnSe<sub>2</sub>, (b) Sn 3d scan, (c) Se 3d scan



Figure 24: SnSe<sub>2</sub>-0.50% GO: XPS spectra of (a) Se 3d, (b) Sn 3d, and (c) O 1s

Graphene	0 wt.%	0.05 wt.%	0.1 wt.%	0.25 wt.%	0.5 wt.%
		Co	mposition (at.	%)	
Sn	20.7	22.2	23.9	18.7	20.5
Se	8.1	5.8	5.0	6.6	7.1
С	29.8	26.5	23.5	33.5	33.5
0	41.9	45.5	47.5	41.3	38.9

Table 10: Composition of SnSe<sub>2</sub> and SnSe<sub>2</sub>-Graphene composites

Figure 25 shows the SEM images for SnSe<sub>2</sub> and its composites. Hexagonal plates are visible in all images. However, rod-like structures are also observed. The nanoparticles had an irregular shape for all the composites, with the SnSe<sub>2</sub>-0.25% GO composite having the most irregular structure (Figure 25 (j,k,l)). The presence of sphere-like structures was also observed. The thickness of the plates was 450.9 nm in the pure SnSe<sub>2</sub>, but with the presence of large agglomerates. The thickness of the plates in the SnSe<sub>2</sub>-0.50% GO composite was 89 nm. The size of the sphere-shaped nanoparticles was estimated to be between 5 to 20 nm.

To further analyze the structure of the synthesized compounds, TEM analysis was performed. Figure 26 shows the results for the TEM. The interplanar spacing obtained from the TEM images was 0.34 nm for all materials. It was also visible that the materials formed had a hexagonal shape, with the images of 0.10% GO composite showing some more irregular shapes. It is not easy to differentiate between the reduced graphene oxide and tin selenide phases, and there is a high amount of agglomeration observed due to the powder not being appropriately dispersed before running the analysis.



Figure 25: SEM images of SnSe<sub>2</sub> and SnSe<sub>2</sub>-Graphene composites



*Figure 26: TEM images of (a,b) pure SnSe<sub>2</sub>, (c,d) SnSe<sub>2</sub>-0.05% GO, (e,f) SnSe<sub>2</sub>-0.10% GO, (g,h) SnSe<sub>2</sub>-0.25% GO, and (i,j) SnSe<sub>2</sub>-0.50% GO* 

# 5.1.2 Thermal Properties

As shown in Figure 27, DSC was performed for the SnSe<sub>2</sub>-GO composites. DSC is an essential thermal analysis technique as it can provide the melting temperature of a material, which is an essential factor to consider when the material is sintered for TE testing. It can be used to obtain the maximum service temperature of a material. The analysis was done from ambient temperature to a temperature of 450 °C. This test was also

performed so the specific heat capacity, Cp, could be determined for the material, as required for the measurement of thermal conductivity.

An endothermic peak was observed around 215 °C for all samples, correlating to the melting point of Se (220 °C). No exothermic phase transformations were present near the same temperature for the composites. An endothermic peak was also observed below 100 °C for all composites, attributed to the evaporation of residual water or ethanol. Table 11 summarises all thermal parameters obtained from the DSC analysis.

Material	Onset Temperature, T₀ (°C)	Peak Temperature, T <sub>p</sub> (°C)	$\Delta \mathbf{H}_{\mathrm{fusion}}$ (J/g)
Pure SnSe <sub>2</sub>	195.3	211.7	9.79
SnSe <sub>2</sub> -0.05% GO	203.7	216.7	20.1
SnSe <sub>2</sub> -0.10% GO	208.3	216.7	8.55
SnSe <sub>2</sub> -0.25% GO	208.8	216.8	18.5
SnSe <sub>2</sub> -0.50% GO	195.3	214.7	15.0

Table 11: Thermal parameters for SnSe<sub>2</sub> and SnSe<sub>2</sub>-GO composites obtained from DSC analysis



Figure 27: DSC thermograms of SnSe<sub>2</sub>-GO composites, performed from ambient to 450 °C under  $N_2$  atmosphere

The thermal stability of pure SnSe<sub>2</sub> and SnSe<sub>2</sub>-graphene composites was evaluated using TGA. The materials showed poor thermal stability, as evident in Figure 28. The mass of the tested samples decreased to around 59%, with the highest GO loading composites losing the most mass (0.25% and 0.5%). No clear pattern was observed, as the composite with 0.1% GO lost the least mass. The composites with 0.25% and 0.50% GO appear to stabilize after a temperature of 500 °C, while the rest do not. A decrease in mass starts at 300 °C, but the simultaneous DSC signal does not show any thermal transformations at this temperature. This trend was not previously reported for SnSe<sub>2</sub>.



Figure 28: TGA for SnSe<sub>2</sub> and SnSe<sub>2</sub>-Graphene composites heated at 10 °C/min under  $N_2$  atmosphere

Thermal conductivity testing was carried at room temperature for the pure SnSe<sub>2</sub> and the SnSe<sub>2</sub>-graphene nanocomposites. The Cp was 0.41 J/g.°C and 0.36 J/g.°C for the pure SnSe<sub>2</sub> and the composite sample, respectively, as measured by DSC. The thermal diffusivity measured by the laser flash technique is used to calculate the thermal conductivity using  $\kappa = \alpha \rho C_p$  was used to calculate the thermal conductivity. The thermal conductivity is the lower for SnSe<sub>2</sub> having graphene oxide loading of 0.5%. This value is 0.41 ± 0.01 W m<sup>-1</sup> K<sup>-1</sup>. The thermal conductivity of the pure SnSe<sub>2</sub> sample was determined to be 0.60 ± 0.01 W m<sup>-1</sup> K<sup>-1</sup>. Compared to the thermal conductivity of the pure SnSe<sub>2</sub>, there was a 31.7% decrease. The results can be seen in Figure 29.



Figure 29: Thermal conductivity, k, and thermal diffusivity,  $\alpha$ , for the SnSe<sub>2</sub>-graphene nanocomposites

The trend followed by the samples is decreasing thermal conductivity as the GO concentration increases. The thermal diffusivity follows the same trend. The thermal diffusivity showed a decrease of 26% at the highest graphene loading, decreasing from  $0.003 \text{ cm}^2/\text{s}$  to  $0.0022 \text{ cm}^2/\text{s}$ . There is a minimum in  $\kappa$  at 0.05% graphene loading.

Although the lowest  $\kappa$  is obtained for the 0.50% GO nanocomposite, a similar  $\kappa$  was also observed for the 0.05% GO nanocomposite, attributed to the significant grain size reduction in the 0.05% GO nanocomposite, as observed in Table 9. Both nanocomposites showed a similar trend in the grain size reduction, with the decrease in the grain size for the 0.50% GO being higher. To better understand the effect of graphene on the thermal conductivity, more nanocomposites with lower graphene concentration should be formed, and their thermal conductivities measured.

The thermal conductivity for the synthesized  $SnSe_2$  is lower than that is reported for  $SnSe_2$  nanomaterials, shown in Table 12. This lower thermal conductivity is particularly significant compared with that of  $SnSe_2$  prepared using hydrothermal methods, as the thermal conductivity obtained in this study is the lowest for the pure  $SnSe_2$ . Additionally, the reported thermal conductivity of the doped  $SnSe_2$  is also higher than both the pure  $SnSe_2$  and the  $SnSe_2$ -graphene nanocomposites prepared in this study, which is a very promising result. A further decrease in  $\kappa$  could be obtained by doping the graphene nanocomposites and optimizing the dopant and the doping concentration.

Preparation Technique	Filler	K undoped, K doped (W/m.K)	Ref.
Solution-based synthesis and hot pressing	No filler	0.44, -	[78]
Solution-based synthesis and hot pressing	Chlorine	0.42, 0.67	[83]
Vacuum melting and hot pressing	Chlorine	1.9, 2.05	[84]
Hydrothermal synthesis and SPS	Ag introduction and chlorine doping	1.65, 1.22	[85]
Hydrothermal synthesis and SPS	AgCl	1.15, 1.05	[86]
Solid-state method and SPS	Chlorine	1.53, 1.39	[87]
Ball milling	Silver	2.98, 2.60	[88]
Hydrothermal synthesis and SPS	Chlorine	1.18, 1.24	[89]
Melting, quenching, and hot pressing	Bromine	1.10, 1.40	[90]
Vacuum melting and hot pressing	Chlorine	1.0, 1.10	[91]

Table 12: Thermal conductivities of SnSe<sub>2</sub>-based materials from literature

# 5.1.3 Mechanical Properties

The hardness of pure  $SnSe_2$  (0.69 GPa) is consistent with reported cross-plane hardness in the of 0.71 GPa, which is twice the in-plane hardness of 0.35 GPa [117].

Figure 30 shows that the hardness increases as the concentration of graphene increases with a 26% increase in hardness with 0.5 wt.% graphene, revealing the excellent reinforcing effect of graphene and suggesting good dispersion in the SnSe<sub>2</sub> matrix.



Figure 30: Effect of graphene loading on the hardness of SnSe<sub>2</sub>

## **5.2 Bismuth Telluride Based Materials**

Bismuth telluride and its composites were synthesized via a solvothermal approach.

So far, the following materials have been synthesized for Bi<sub>2</sub>Te<sub>3</sub>:

• Pure Bi<sub>2</sub>Te<sub>3</sub>,

- Doped pure Bi<sub>2</sub>Te<sub>3</sub>,
- Bi<sub>2</sub>Te<sub>3</sub>-graphene composites (0.5% and 0.25% GO).

A yield higher than 95% was obtained for all four materials. Their structure was studied by performing XRD and XPS, and the thermal behavior of these materials was studied using TGA.

# 5.2.1 Chemical and Structural Properties

Figure 31 shows the XRD patterns of the synthesized pure  $Bi_2Te_3$  and the composites with GO. The peaks confirm the synthesis of  $Bi_2Te_3$ .  $Bi_2Te_3$  has a characteristic peak at 27.6°, which represents the (1 0 4) plane. The composite spectrum shows two extra peaks at 30.48° and 32.26°, attributed to  $Bi_2O_3$  [118, 119]. The presence of oxides can be confirmed with XPS analysis.



Figure 31: XRD patterns of pure Bi<sub>2</sub>Te<sub>3</sub> and Bi<sub>2</sub>Te<sub>3</sub>-graphene composites.

For pure  $Bi_2Te_3$ , further analysis was carried out. The interplanar distance of the (1 0 4) plane was 0.322 nm, obtained using Bragg's Law. The grain size was calculated using the Williamson-Hall method, and the same procedure as detailed in Section 5.1.1 Chemical and Structural Properties was followed. The average grain size for the crystals was found to 36.5 nm. The linear fit plot can be seen in Figure 32. A strain of 0.46% was determined.



Figure 32: Williamson-Hall linear fit for pure Bi<sub>2</sub>Te<sub>3</sub> crystals

The R<sup>2</sup> value suggests a good fit for the data. However, the analysis was also repeated using the Warren-Averbach method as it was a more accurate model for SnSe<sub>2</sub>. Figure 33 shows a linear fit for  $\frac{\beta^2}{\tan^2 \theta}$  vs  $\frac{\beta \lambda}{\tan \theta \sin \theta}$ , The grain size and strain were obtained from the slope and the intercept, respectively. The R<sup>2</sup> value for the Warren-Averbach method is lower, suggesting that the Williamson-Hall method is a better fit. The grain size was 33 nm, and the strain was 0.44 %.



Figure 33: Warren-Averbach linear fit for pure Bi<sub>2</sub>Te<sub>3</sub> crystals

Similarly, the grain size for the doped  $Bi_2Te_3$  and the GO composites were also calculated. Unlike the pure crystals, the Warren-Averbach method was found to be a better fit. The grain size decreased significantly upon the addition of graphene and upon doping with silver. The smallest grain size was found for the 0.50% GO nanocomposites, showing a decrease of 54.7% as compared to the size of the pure  $Bi_2Te_3$ .

Table 13 summarises the strain and grain sizes calculated by the Scherrer, Williamson-Hall, and Warren-Averbach methods.

Description	Grain Size (nm)			
	Scherrer's Method	Williamson-Hall	Warren-Averbach	
Pure Bi <sub>2</sub> Te <sub>3</sub>	14.35	36.52	33.00	
Ag-doped Bi <sub>2</sub> Te <sub>3</sub>	23.68	21.03	15.34	

Table 13: Grain size of pure Bi2Te3 and Bi2Te3-based materials obtained using Scherrer,Williamson-Hall, and Warren-Averbach methods

Decemintion	Grain Size (nm)		
Description	Scherrer's Method	Williamson-Hall	Warren-Averbach
Bi <sub>2</sub> Te <sub>3</sub> -0.25% GO	20.28	27.76	19.16
Bi <sub>2</sub> Te <sub>3</sub> -0.50% GO	17.29	9.64	14.99

However, the Ag-doped material also showed a significant decrease, suggesting an even smaller grain size could be obtained upon combining the doping and graphene nanocompositing techniques. The graphs for all composites can be found in Appendix A.2.



Figure 34: (a) Survey spectra of the pure Bi<sub>2</sub>Te<sub>3</sub>, (b) Bi 4f scan, (c) Te 3d scan

XPS confirmed the synthesis of  $Bi_2Te_3$ , with both Bi and Te spectra showing peaks that correspond to  $Bi_2Te_3$ . Figure 34 (b) and (c) show the spectra obtained for Bi 4f and Te 3d, respectively. Four peaks were observed for Bi 4f – two at 157.8 eV and 163.1 eV, which can be attributed to  $Bi_2Te_3$ . The peaks at 158.8 eV and 164 eV correspond to bismuth oxide,  $Bi_2O_3$  [120]. Similarly, four peaks were also observed for Te 3d. The peaks at 574.7 eV and 584 eV can be attributed to Te  $3d_{5/2}$  and Te  $3d_{3/2}$ , respectively. They correspond to  $Bi_2Te_3$ . The peaks at 577.2 eV and 587.6 eV correspond to tellurium oxide, TeO<sub>2</sub> [120]. Table 14 summarises the elemental composition results. It can also be observed that for the composites, the composition of bismuth and tellurium is lower.

The XPS spectra for the GO composites are similar, showing the peaks observed in Figure 35. The Bi 4f scan shows similar peaks like the ones obtained for the pure Bi<sub>2</sub>Te<sub>3</sub>. However, the tellurium scan differs. In addition to the Bi<sub>2</sub>Te<sub>3</sub>, Te, and tellurium oxide (TeO<sub>3</sub>) peaks, there are also peaks at 572.2 eV and 582.6 eV, corresponding to pure Te.



Figure 35: XPS analysis of Bi<sub>2</sub>Te<sub>3</sub>-0.25% GO (a) Bi 4f scan, (b) Te 3d scan

Matarial	Composition (at. %)			
Materiai	Bi	Te	С	0
Pure Bi <sub>2</sub> Te <sub>3</sub>	22.07	15.03	-	62.3
Ag-doped Bi <sub>2</sub> Te <sub>3</sub>	19.99	18.57	-	61.44
Bi <sub>2</sub> Te <sub>3</sub> -0.25% GO	10.8	7.53	43.36	38.31
Bi <sub>2</sub> Te <sub>3</sub> -0.50% GO	11.05	7.54	40.36	41.04

Table 14: Elemental quantification of Bi<sub>2</sub>Te<sub>3</sub> and Bi<sub>2</sub>Te<sub>3</sub> composites

Figure 36 shows the SEM images for all Bi<sub>2</sub>Te<sub>3</sub>-based samples that were synthesized. The images all show hexagonal plates, along with wood-like structures observed for the GO composites. The pure and doped samples show more plates than the composites. The composites show more irregular structures than the pure samples, also showing needle-like structures.

The needle-like structure observed in the SEM images for the  $Bi_2Te_3$ -graphene composites was further studied. The elemental mapping for the structure can be seen in Figure 37 (b) and (c) for the structure in  $Bi_2Te_3$ -0.25% GO (seen in Figure 36 (j)). As observed in Figure 37 (b), the structure contained mainly tellurium, with low bismuth, consistent with the elemental mapping of these needles in  $Bi_2Te_3$ -0.5% GO as well.

A wood-like structure was observed for all of the samples. The structures were further studied using EDS. Figure 38 (a) shows the SEM image for the structure in  $Bi_2Te_3$ with 0.50% graphene loading. The elemental mapping of Te in Figure 38 (b) indicates that the structures contain high tellurium and confirmed by the EDS chemical analysis, which was 81.64%. The XPS scans for the composites also showed the presence of free Te within the nanopowders. The composition of oxygen and carbon is homogenous through the surface, as seen in Figure 38 (d) and (e). However, this was not constant across all samples, with other samples showing a more uniform distribution. EDS studies and elemental mapping of the  $Bi_2Te_3$ -0.25% GO and pure  $Bi_2Te_3$  samples showed that the composition of this structure also had high amounts of bismuth.



Figure 36: SEM images of (a-c) pure Bi<sub>2</sub>Te<sub>3</sub> with CTAB, (d-f) pure Bi<sub>2</sub>Te<sub>3</sub> without CTAB, (g-i) Ag-doped Bi<sub>2</sub>Te<sub>3</sub>, (j-l) Bi<sub>2</sub>Te<sub>3</sub>-0.25% GO, and (m-o) Bi<sub>2</sub>Te<sub>3</sub>-0.25% GO



Figure 36 Continued



*Figure 37: (a) SEM image of the needle-like structure in Bi*<sub>2</sub>*Te*<sub>3</sub>*-0.25% GO and corresponding EDS mapping on the surface for (b) Te, and (c) Bi.* 



*Figure 38: (a) SEM image of the wood-like structure in Bi*<sub>2</sub>*Te*<sub>3</sub>*, and corresponding EDS mapping on the surface for (b) Te, (c) Bi, (d) O, and (e) C* 

#### 5.2.2 Thermal Properties

As shown in Figure 39, DSC was performed on the various synthesized  $Bi_2Te_3$  nanopowders. An endothermic melting peak is observed for all variants (excluding doped  $Bi_2Te_3$ ) at an onset temperature of 417.7 °C, which can be attributed to a eutectic peak for  $Bi_2Te_3$  and Te as reported in the literature [121]. An exothermic phase transformation is observed at a temperature of around 400 °C for the materials that gave an endothermic peak. The curves for pure  $Bi_2Te_3$  show several thermal events. An endothermic peak was observed at an onset temperature of 95 °C, which could be due to the evaporation of water. Melting and consequent fusion peaks were also observed at onset temperatures of 265.94

and 269.17 °C, respectively. The melting can be attributed to the melting of any free bismuth present within the sample. Peaks at an onset temperature of ~265 °C were also observed for the GO composites. Conversely, no significant peaks were observed in the curves for Ag-doped Bi<sub>2</sub>Te<sub>3</sub>. Multiple cycles should be performed in the DSC to assess the thermal stability of the synthesized materials properly. Table 15 summarises all thermal parameters obtained from the DSC analysis.



*Figure 39: DSC of various Bi*<sub>2</sub>*Te*<sub>3</sub> *nanopowders, performed from ambient to 450 °C under N*<sub>2</sub> *atmosphere* 

	Heating			Cooling	
Material	T <sub>m</sub> (°C)	Enthalpy (J/g)	Onset. (°C)	Enthalpy (J/g)	
$2: T_{0} = 0.250/CO$	265.2	0.58	401.5	-18.9	
6121 e3-0.25% GO	417.6	13.02	401.5		
. T. 0 500/ CO	264.8	1.55	404.2	-23.2	
121 e3-0.50% GO	417.7	15.09			
	95.4	2.19	396.4	-18.9	
	127.5	4.83			
Pure Bi <sub>2</sub> Te <sub>3</sub>	265.94	0.12			
	269.17	-7.98			
	417.3	0.28			

*Table 15: Thermal parameters for Bi*<sub>2</sub>*Te*<sub>3</sub>*-based materials obtained from DSC analysis* 

The thermal stability of the  $Bi_2Te_3$  materials was also investigated by conducting TGA. Figure 40 depicts how weight changes with an increase in temperature. An increase in the mass is observed for the three samples, which can be attributed to the reaction of an intermediate product with nitrogen consistent with previously reported [122]. The Ag-doped sample shows a decrease in weight at ~ 100 °C, followed by constant weight at 150 °C and another increase in weight at 300 °C with a spike at 400 °C. This behavior was not previously reported.



Figure 40: TGA of Bismuth Telluride samples heated at 10  $^{\circ}C/min$ , under  $N_2$  atmosphere

#### 6. CONCLUSION AND FUTURE WORK

In this research, pure tin selenide and bismuth telluride and their composites with GO were synthesized using a scalable solution method. Tin selenide synthesis used tin chloride and selenium dioxide as the precursors, with hydrazine used as the reducing agent. The synthesis of the thermoelectric materials was confirmed by XRD analysis. The presence of pure selenium was also detected in the composites, confirmed by XRD and XPS. Thermal conductivity testing carried out for SnSe<sub>2</sub> gave a low value (0.60 W/m.K), favorable for TE applications. The addition of GO reduced the thermal conductivity further, giving a minimum value of 0.41 Wm<sup>-1</sup>K<sup>-1</sup> at 0.50% GO loading. The hardness measurements carried out for SnSe<sub>2</sub> gave results agreeable with the literature. XPS detected the presence of oxides within the sample. However, the TGA and DSC curves of the materials showed that their thermal stability requires improvement, as a high amount of weight loss was observed in the TGA, along with melting in the DSC analysis.

Bismuth telluride and the composites with graphene oxide were prepared using bismuth chloride and pure tellurium powder, with sodium borohydride used as the reducing agent. An Ag-doped sample of bismuth telluride was also prepared. XRD confirmed the successful synthesis of the material, and XPS for the materials indicated a high amount of oxygen in the materials, with oxides of both bismuth and tellurium present. Ag-doped Bi<sub>2</sub>Te<sub>3</sub> was also synthesized. TGA for the bismuth telluride samples showed low to no loss in mass, suggesting good stability. However, the DSC analysis showed melting around 269 °C for the samples, suggesting a free bismuth present. The low thermal conductivity of the tin selenide samples suggest favorable TE properties can be obtained from these materials, and the reduction of the thermal conductivity due to the addition of graphene is also promising. Moreover, graphene also enhanced the mechanical properties, as demonstrated by a 26% increase in hardness. For the bismuth telluride-based materials, the thermal stability of the nanopowders is favorable for applications within the tested temperature range. A reduction in grain size was also observed for both systems upon the addition of graphene.

Despite the promising properties in the preliminary analysis, both the tin selenide and bismuth telluride samples could not be sintered successfully due to melting during the heating process. To correct this, the synthesis must be repeated to ensure no free metals are present so that the TE performance testing can be performed, and the impact of adding graphene to the pure materials can be studied. The effect of premixing, synthesis time, and temperature, and the amount of the reducing agent used must be tuned to ensure no impurities are present. In addition to optimizing the synthesis process, doped graphene nanocomposites should also be produced to analyze any effect that coupling the three methods (nanostructuring, nanocompositing, and doping) could have on the thermal and electrical properties of these materials.

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## **APPENDIX A**

## Appendix A.1

This section provides additional details for the tin selenide analyses.



Figure A. 1: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for  $SnSe_2$ -0.05% GO composite. The  $R^2$  value for (b) is higher, suggesting Warren-Averbach is a better fit.



Figure A. 2: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for SnSe2-0.10% GO composite. The  $R^2$  value for (b) is higher, suggesting Warren-Averbach is a better fit.



Figure A. 3: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for SnSe2-0.25% GO composite. The  $R^2$  value for (b) is higher, suggesting Warren-Averbach is a better fit.



Figure A. 4: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for SnSe2-0.25% GO composite. The  $R^2$  value for (b) is higher, suggesting Warren-Averbach is a better fit.



Figure A. 5: SnSe<sub>2</sub>-0.05% GO: XPS spectra of (a) Se 3d, (b) Sn 3d, and (c) O 1s



Figure A. 6: SnSe<sub>2</sub>-0.10% GO: XPS spectra of (a) Se 3d, (b) Sn 3d, and (c) O 1s 104



Figure A. 7: SnSe<sub>2</sub>-0.25% GO: XPS spectra of (a) Se 3d, (b) Sn 3d, and (c) O 1s

## Appendix A.2



This section provides additional details for the bismuth telluride analyses.

*Figure A. 8: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for Ag-doped Bi*<sub>2</sub>*Te*<sub>3</sub>*. The R*<sup>2</sup> *value for (b) is higher, suggesting Warren-Averbach is a better fit.* 



Figure A. 9: Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for Bi<sub>2</sub>Te<sub>3</sub>-0.25% GO. The R<sup>2</sup> value for (b) is higher, suggesting Warren-Averbach is a better fit.



*Figure A.* 10: *Linear fits of (a) Williamson-Hall and (b) Warren-Averbach models for Bi*<sub>2</sub>*Te*<sub>3-0.50%</sub> *GO. The R*<sup>2</sup> *value for (b) is higher, suggesting Warren-Averbach is a better fit.* 



Figure A. 11: XPS analysis of Bi<sub>2</sub>Te<sub>3</sub>-0.50% GO (a) Bi 4f scan, (b) Te 3d scan